The international journal & abstracting service for Vacuum Sciences & Technology

VACUUM

SURFACE ENGINEERING, SURFACE INSTRUMENTATION & VACUUM TECHNOLOGY

Volume 52–55, 1999

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Publication information: Vacuum (ISSN 0042-207X). For 2000, volumes 56–59 are scheduled for publication. Subscription prices are available upon request from the Publisher or from the Regional Sales Office nearest you or from this journal's website (http://www.elsevier.nl/locate/vacuum). Further information is available on this journal and other Elsevier Science products through Elsevier's website: (http://www.elsevier.nl). Subscriptions are accepted on a prepaid basis only and are entered on a calendar year basis. Issues are sent by standard mail (surface within Europe, air delivery outside Europe). Priority rates are available upon request. Claims for missing issues should be made within six months of the date of dispatch.

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Periodicals postage is paid at Rahway, NJ. Vacuum (ISSN 0042-207X) is published monthly, January to December in 4 volumes with extra issues in March, June, September and December, by Elsevier Science Ltd., The Boulevard, Langford Lane, Kidlington, Oxford OX5 1GB, UK. The US subscription price is $2242.00 per year.

POSTMASTER: Send address corrections to: Vacuum, Elsevier Science, Customer Support Department, PO Box 945, New York, NY 10159-0945. **Distributed** in the USA by Mercury Airfreight International, 365 Blair Road, Avenel, NJ 07001.

Typeset in India by Macmillan India Ltd., Bangalore-25. Printed and bound in Great Britain at Polestar-AUP Aberdeen Ltd.

PERGAMON

Vacuum 55 (1999) V–XX

VACUUM
SURFACE ENGINEERING, SURFACE INSTRUMENTATION & VACUUM TECHNOLOGY

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Contents

Volume 52 Numbers 1–2

AUTHORS		ARTICLES
J L de Segovia	1	Foreword
V J Herrero and I Tanarro	3	Production and applications of atomic and molecular beams
F L Tabarés	11	Gas sources in fusion devices
P L Vieira and R F M Lobo	19	Low energy electron beam for time-of-flight ionization measurements
C M M Leitão, T A Gasche, G Bonfait, O M N D Teodoro and A M C Moutinho	23	UHV sample holder for fast heating and cooling cycles
J-C Legrand, A-M Diamy, R Hrach and V Hrachova	27	Mechanisms of methane decomposition in nitrogen afterglow plasma
M Touzeau, D Pagnon and J Bretagne	33	Spectroscopic study and modeling of a reactive magnetron discharge in Ar/O_2 and in air
E Fourtunato, A Malik and R Martins	41	Amorphous silicon thin films applied to photochemical sensors
P Nunes, A Malik, B Fernandes, E Fortunato, P Vilarinho and R Martins	45	Influence of the doping and annealing atmosphere on zinc oxide thin films deposited by spray pyrolysis
X Redondas, P González, B León and M Pérez-Amor	51	Silicon-carbon thin films deposited by excimer lamp-CVD from disilane and ethylene
E Márquez, P Nagels, J M González-Leal, A M Bernal-Oliva, E Sleeckx and R Callaerts	55	On the optical constants of amorphous Ge^xSe^{1-x} thin films of non-uniform thickness prepared by plasma-enhanced chemical vapour deposition
M J M Gomes	61	On the preparation of PLZT thin films grown by pulsed laser deposition
M Vieira, E Morgado, A Maçarico, S Koynov and R Schwarz	67	Microcrystalline silicon thin films for optical applications
R A Nevchoupa, J L de Segovia and E A Deulin	73	An UHV system to study gassing and outgassing of metals under friction
A Fernández, E P Reddy, T C Rojas, and J C Sánchez-López	83	Application of the gas phase condensation to the preparation of nanoparticles
L F Casinhas, M de L Fraser Monteiro, D Liang, U Boesl, H Nagel and E W Schiag	89	A pyrolysis cell as simulator for an automobile catalytic converter
O Zelaya-Angel, A Picos-Vega, R Ramirez-Bon and F J Espinoza-Beltrán	99	Interstitial Cd doping CdTe films by co-sputtering
I Colera, E Soria, J L de Segovia and R González	103	Study of fluorine contamination of MgO(100) surfaces

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S0042-207X(99)00182-7

A de Bernabé, M J Capitán, H E Fischer, S Lequien, F J Mompeán, C Prieto, C Quirós, J Colino, S Lefebvre, M Bessière and J M Sanz	109	Oxidation study of Co/Cu multilayers by resonant X-ray reflectivity
Teresa M R Viseu and M I C Ferraira	115	Morphological characterization of TiO_2 thin films
M Vieira, A Maçarico, A Fantoni, M Fernandes, S Koynov and R Schwarz	121	Visible-infrared spectral response of microcrystalline hydrogenated silicon hetero-junctions
D Camino, A H S Jones, D Mercs and D G Teer	125	High performance sputtered carbon coatings for wear resistant applications
J Esteve, M C Polo and G Sánchez	133	Diamond and diamond-like carbon films
J L Viviente, A Garcia, A Loinaz, F Alonso and J I Oñate	141	Carbon layers formed on steel and Ti alloys after ion implantation of C^+ at very high doses
I Ferreira, B Fernandes and R Martins	147	Nanocrystalline silicon carbon doped films prepared by hot wire technique
J L Andújar, G Viera, M C Polo, Y Maniette and E Bertran	153	Synthesis of nanosize Si–C–N powder in low pressure plasmas
A Cavaleiro, C Louro, J V Fernandes and C M A Brett	157	Use of ultramicroindentation to evaluate the degradation of sputtered coatings
Q H Fan, A Fernandes, E Pereira and J Grácio	163	Evaluation of adherence of diamond coating by indentation method
F Rossi, C Schaffnit, L Thomas, H del Puppo and R Hugon	169	Plasma assisted chemical vapour deposition of boron nitiride coatings from using BCl_3–N_2–H_2–Ar gas mixture
G Viera, S N Sharma, J L Andújar, R Q Zhang, J Costa and E Bertran	183	Nanometric powder of stoichiometric silicon carbide produced in square-wave modulated RF glow discharges
R J Rodriguez, A Sanz, A Medrano, and J A Garcia-Lorente	187	Tribological properties of ion implanted Aluminium alloys
Q H Fan, A Fernandes, E Pereira and J Gracio	193	Adherent diamond coating on copper using an interlayer
C Quiros, R Núñez, P Priato, E Elizalde, A Fernández, M Schubert, C Donnet and J M Sanz	199	Tribological and chemical characterization of ion beam-deposited CN_x films
R Martins, I Ferreira, B Fernandes and E Fortunato	203	Performances of a-Si:H films produced by hot wire plasma assisted technique
F Vaz, L Rebouta, R M C da Silva, M F da Silva and J C Soares	209	Characterization of titanium silicon nitride films deposted by PVD
A J Fernandes, P J Ventura, R F Silva and M C Carmo	215	Porous silicon capping by CVD diamond

Volume 52 Number 3

AUTHORS		ARTICLES
Z Y Ning, S Y Guo and S H Cheng	219	Numerical simulation of plasma flow downstream in an ECR plasma deposition apparatus

A Markowski and L Michalak	225	Ion generation from the interaction of focused photon and effusing molecular beams
S Zhao-Qi, S Da-Ming, L Ai-Xia and X Zhi-Yuan	243	Optical properties of Ag–MgF_2 cermet films
Y Sharkeev, B Gritsenko, S Fortuna and A Perry	247	Modification of metallic materials and hard coatings using metal ion implantation
W Opydo	255	The influence of coatings and the surface state on the electric strength of vacuum insulated electrodes used with a 50 Hz supply
A Pelc and L Michalak	261	Electron impact study of carbon disulphide micro-clusters
J Musil and P Zeman	269	Structure and microhardness of magnetron sputtered ZrCu and ZrCu-N films
M Fadel	277	The effect of the Sb content on the physical properties of amorphous $Se_{0.75}Ge_{0.25-x}$ thin films
G Mesyats, Yu Klyachkin, N Gavrilov and A Kondyurin	285	Adhesion of Polytetrafluorethylene modified by an ion beam
B Hjörvarsson, A Stierle, G Song and H Zabel	291	Hydrogen affinity at Cr/α–Cr_2O_3 metal/oxide interfaces studied by the $^1H(^{15}N, \alpha\gamma)^{12}C$ nuclear resonance reaction
N V Egorov and A A Almazov	295	Optimization of multi-tip field emission electron source
D Manova, V Dimitrova, D Karpuzov and R Yankov	301	Reactively DC magnetron sputtered thin AlN films studied by X-ray photoelectron spectroscopy and polarised infrared reflection
M Komath, G Mohan Rao and S Mohan	307	Studies on the optimisation of unbalanced magnetron sputtering cathodes
M Alves, O Balachova, E Braga and L Cescato	313	Selective deposition of amorphous hydrogenated carbon films used as masks for reactive ion etching of Si using CF_4
R Wang	315	Investigation of the properties of an anodic vacuum arc
T Uzunov, S Stojanov and S Lambov	321	Thin films of intermetallic Cu/Ti compounds and their possible uses
S Boukari, J Balay, E Beaurepaire, G Biechel, B Carrière, J P Deville, B Muller and F Scheurer	327	Four pole electromagnet for *in situ* magneto-optical measurements
F Watanabe	333	Dominance of electron-stimulated desorption neutral species in ultra-high vacuum pressure measurements
Y Suetsugu	339	Numerical simulation on vacuum pressure distribution inside a rotating cylinder
C Sun	347	Mechanism for the N–Ni(1 0 0) clock reconstruction
V Shutthanandan, J Zhang and P K Ray	353	On the preferential emission of heavy isotopes in sputtering
S A Fayek and S S Fouad	359	Topological consideration of thallium on glassy arsenous selenide
T Dimitrov Uzunov, S Petrov Stojanov and S Ivanov Lambov	365	Contact-reactive welding of titanium via a copper layer
Book reviews		
W Steckelmacher	370	Encyclopedia of Applied Physics

D Briggs 371 Surface Analysis of Polymers by XPS and STATIC SIMS

A Bossavit 372 Computational Electromagnetism: Variational Formulations Complementarity, Edge Elements

G Bertotti 373 Hysteresis in Magnetism For Physicists, Materials Scientists, and Engineers

Volume 52 Number 4

AUTHORS ARTICLES

D A Hady, H. Soliman, A El-Shazly and M S Mahmoud 375 Electrical properties of $SnSe_2$ thin films

S Da-Ming, S Zhao-Qi, L Ai-Xia and X Zhi-Yuan 381 XPS analysis of the oxidation of Ag–MgF_2 cermet film

W I Hamdi 387 The effect of illumination with intense light on the conduction current of metal/n-silicon diodes

C Dominguez, J A Rodriguez, F J Muñoz and N Zine 395 Plasma enhanced CVD silicon oxide films for integrated optic applications

M N El-Shazly, A V Tikhomirov, G G Gulbekian and P Kováč 401 GENAP—the code for a pressure distribution calculation

V S Kharlamov, D V Kulikov and Yu V Trushin 407 Computer simulation of transition from h-BN to c-BN during ion beam assisted deposition

C Junfang and R Zhaoxing 411 Ion energy distribution in an ECR plasma chamber

H Biederman, V Stundžia, D Slavinská and J Glosík 415 Characterization of an unbalanced magnetron for composite film (metal/C:H) deposition

E Paparazzo, L Moretto, S Selci, M Righini and I Farnè 421 Effects of HF attack on the surface and interface microchemistry of W tips for use in the STM microscope: a scanning Auger microscopy (SAM) study

P K Petrov, V A Volpyas and R A Chakalov 427 Three-dimensional Monte Carlo simulation of sputtered atom transport in the process of ion-plasma sputter deposition of multicomponent thin films

W Helin, L Zuli and Y Kailun 435 Monte Carlo simulation of thin-film growth on a surface with a triangular lattice

W Słowko 441 Directional detection of secondary electrons for electron beam profilography

L-C Valdès, B Barthod and Y Le Perron 451 Accurate prediction of internal leaks in stationary dry Roots vacuum pumps

M Čekada, P Panjan, B Navinšek and F Cvelbar 461 Characterization of (Cr,Ta)N hard coatings reactively sputtered at low temperature

P R Deshmukh, K J Rangra and O P Wadhawan 469 Resist debris formation in electron beam lithography

T Stenberg, J Keränen, P Vuoristo, T Mäntylä, S Virtanen, P Schmuki, M Büchler and H Böhni 477 Characterisation of r.f. sputtered Fe–Cr-oxide films

S K Mandal, A Gangopadhyay, S Chaudhuri and A K Pal 485 Electron transport process in discontinuous silver film

K Jousten, P Röhl and V A Contreras	491	Volume ratio determination in static expansion systems by means of a spinning rotor gauge
P Petrov, D Dimitrov, G Beshkov, V Krastev, S Nemska and Ch Georgiev	501	Carbon nitride films synthesized by electron beam evaporation of carbon and nitrogen ion bombardment
S S Fouad	505	A theoretical investigation of the correlation between the arbitrarily defined optical gap energy and the chemical bond in $Te_{46-x}As_{32+x}Ge_{10}Si_{12}$ system
I Batty, M Cooke and V J Law	509	Harmonic characterisation of a plasma-tool using a diplexer
Book Reviews	515	
VACUUM DIARY	I	

Volume 53 Numbers 1–2

14th International Vacuum Congress (IVC-14)
10th International Conference on Solid Surfaces (ICSS-10)
5th International Conference on Nanometre-scale Science and Technology (NANO 5)
10th International Conference on Quantitative Surface Analysis (QSA-10)

AUTHORS		ARTICLES
Publisher's Announcement	ix	
Preface	xi	
PLASMA SCIENCE DIVISION		
G Viera, J Costa, F J Compte, E García-Sanz, J L Andújar and E Bertran	1	Accurate electrical measurements for in situ diagnosis of RF discharges in plasma CVD processes
R Jothilingam, T Farrell, T B Joyce, T J Bullough and P J Goodhew	7	Comparison of in situ optical reflectance and post-growth characterisation of quantitative composition and thickness determination of $Al_xGa_{1-x}As$
W M Posadowski and A Brudnik	11	Optical emission spectroscopy of self-sustained magnetron sputtering
C Molle, A Beauvois, M Wautelet, J P Dauchot and M Hecq	17	Characterization of an inductively amplified magnetron plasma by glow discharge mass spectrometry
E Kusano, T Kobayashi, N Kashiwagi, T Saitoh, S Saiki, H Nanto and A Kinbara	21	Ion energy distribution in ionized dc sputtering measured by an energy-resolved mass spectrometer
G G Bondarenko and V I Kristya	25	Simulation of heavy ion energy distribution function in the cathode sheath of noble gas mixture glow discharge
W Chen, T Hayashi, M Itoh, Y Morikawa, K Sugita and T Uchida	29	Application of magnetic neutral loop discharge plasma to SiO_2 etching process
M Kashiwagi and S Ido	33	Computational analyses of a magnetron sputtering system with a ferromagnetic target

P K Petrov, E K Hollmann, V A Volpyas, A V Volpyas, T Tanaka and K Kawabata — 37 — Preparation of argon-free refractory thin films using RF-DC coupled magnetron sputtering

M Braic, C N Zoita, V Braic, A Kiss, M Popescu and G Musa — 41 — Influence of He, Ne and Kr addition in reactive Ar/N_2 dc magnetron plasma on TiN deposition

G Beensh-Marchwicka, E Prociów and W Posadowski — 47 — Preparation of thermosensitive magnetron sputtered thin films

M Gioti, S Logothetidis, C Charitidis and H Lefakis — 53 — Composition, chemical bonding and mechanical properties of magnetron sputtered CN_x thin films at different substrate bias

VACUUM METALLURGY DIVISION

M Pancielejko, W Precht and A Czyzniewski — 57 — Tribological properties of PVD titanium carbides

S Logothetidis, M Gioti, C Charitidis and P Patsalas — 61 — A new process for the development of hard and stable sputtered amorphous carbon films

E Koleva, G Mladenov and K Vutova — 67 — Calculation of weld parameters and thermal efficiency in electron beam welding

V G Glebovsky and V N Semenov — 71 — The perfection of tungsten single crystals grown from the melt and solid state

I Ibarrondo and J Degauque — 75 — Study of vacuum levels in the annealing of high silicon (6.4 wt%) non-oriented magnetic steel sheets obtained by rapid quenching and its incidence on grains size, texture and core losses

A V Kholzakov, I N Shabanova and A G Ponomarev — 79 — XPS-studies of structure transformation and relaxation processes in transition metal melts

S N Ermolov, R Cortenraad, V N Semenov, A W Denier van der Gon, S I Bozhko, H H Brongersma and V G Glebovsky — 83 — Growth and characterization of monocrystalline tungsten substrates

K Vutova and G Mladenov — 87 — Computer simulation of the heat transfer during electron beam melting and refining

K Abiko and S Takaki — 93 — Ultra-purification of iron by ultra-high vacuum melting

S Takaki and K Abiko — 97 — Ultra-purification of iron by three types of melting furnaces constructed using ultra-high vacuum technology

Y Saotome, Y Nakazawa and Y Yamada — 101 — Disassembling and materials recovering process of alkaline manganese dry batteries by vacuum-aided recycling systems technology (VARS Tech.)

V T Volkov, A M Ionov and T V Nikiforova — 105 — Ultrapurification of yttrium metal from oxide to single crystal: results and perspectives

W Precht, M Pancielejko and A Czyzniewski — 109 — Structure and tribological properties of carbon and carbon nitride films, obtained by the ARC method

M A Baker, R Gilmore, C Lenardi P N Gibson and W Gissler — 113 — Microstructure and mechanical properties of multilayer TiB_2/C and co-sputtered TiB_2-C coatings for cutting tools

M Tomlinson, S B Lyon, P Hovsepian and W-D Munz — 117 — Corrosion performance of CrN/NbN superlattice coatings deposited by the combined cathodic arc/unbalanced magnetron technique

Q Luo, W M Rainforth, L A Donohue, I Wadsworth and W-D Münz — 123 — Tribological investigation of TiAlCrN and TiAlN/CrN coatings grown by combined steered-arc/unbalanced magnetron deposition

P Panjan, B Navinšek, M Čekada and A Zalar 127 Oxidation behaviour of TiAlN coatings sputtered at low temperature

I K Fetisov, A A Filippov, G V Khodachenko, D V Mozgrin and A A Pisarev 133 Impulse irradiation plasma technology for film deposition

VACUUM SCIENCE DIVISION

Pressure Measurement and Calibration

P A Redhead 137 The ultimate vacuum

F Watanabe 151 My never-ending story towards XHV pressure measurements

F J Redgrave, A B Forbes and P M Harris 159 A discussion of methods for the estimation of volumetric ratios determined by multiple expansions

B P Butler, V Music and F J Redgrave 163 Influence of orifice geometry on the simplification of transmission probability calculations

L Wangkui, L Qiang, L Shiliang, Z Dixin, M Shilong, H Wei, M Qinhua, L Detian, L Zhenghai, G Yueli, M Yang, W Xinhui, T Dongxu and L Li 167 Dynamic flow method UHV standard apparatus developed by LIP

L Detian, L Zhenghai, M Yang and Z Dixin 173 An apparatus controlled by computer for vacuum gauge calibration

S Suginuma and M Hirata 177 Dependence of sensitivity coefficient of a nude-type Bayard–Alpert gauge on the diameter of an envelope

W Jitschin, M Ronzheimer and S Khodabakhshi 181 Gas flow measurement by means of orifices and Venturi tubes

M Yang, Z Dixin, L Shiliang, G Yueli and L Detian 187 Two dynamic comparison methods for calibrating the rate of pressure leaks

S B Nesterov, Yu K Vassiliev and A P Kryukov 193 Influence of the vacuum chamber shape on the non-uniformity of gas distribution

Residual Gas Analysis and Leak Detection

J K Fremerey 197 Residual gas: traditional understanding and new experimental results

S Taylor, J J Tunstall, J H Leck, R F Tindall, J P Jullien, J Batey, R R A Syms, T Tate and M M Ahmad 203 Performance improvements for a miniature quadrupole with a micromachined mass filter

B Holst, J R Buckland and W Allison 207 Spatial mapping in the electron-impact ion-source of a residual gas analyser

J J Tunstall, S Taylor, A Vourdas, J H Leck and J Batey 211 Application of a static magnetic field to the mass filter of a quadrupole mass spectrometer

S Bryan, J L Hemmerich and T Winkel 215 Developments in helium leak detection at JET

Vacuum Pumping

C Benvenuti, J M Cazeneuve, P Chiggiato, F Cicoira, A Escudeiro Santana, V Johanek, V Ruzinov and J Fraxedas 219 A novel route to extreme vacua: the non-evaporable getter thin film coatings

H-P Cheng, R-Y Jou, F-Z Chen, Y-W Chang, M Iwane and T Hanaoka 227 Flow investigation of Siegbahn vacuum pump by CFD methodology

T Sawada, S Kamada, W Sugiyama, J-i Takemoto, S Haga and M Tsuchiya 233 Experimental verification of theory for the pumping mechanism of a dry-scroll vacuum pump

R P Davis 239 Development of a relative method for comparing the composition of the residual atmosphere above commercial dry-pump systems

A D Chew 243 The measurement of helium retention in forepumps

J P Bojon, N Hilleret and K Weiss 247 Origin of possible contamination introduced by a turbomolecular pumping system

Sorption, Desorption, Outgassing and Permeation

Chr Day and A Schwenk-Ferrero 253 Sticking coefficients for helium and helium-containing mixtures at activated carbon under liquid helium cooling conditions

M De Angeli and F Ghezzi 257 Solution for pressure measurements problems in finding PCT equilibrium characteristics of hydrogen getters

S B Nesterov, Yu K Vassiliev, G L Saksaganski, B A Loginov and V V Protasenko 263 How the sorben microgeometry effects the sorptional characteristics of cryopumps

V V Anashin, O B Malyshev, R Calder and O Gröbner 269 A study of the photodesorption process for cryosorbed layers of H_2, CH_4, CO or CO_2 at various temperatures between 3 and 68 K

R Cimino, V Baglin and I R Collins 273 VUV synchrotron radiation studies of candidate LHC vacuum chamber materials

V Nemanič and J Šetina 277 A study of thermal treatment procedures to reduce hydrogen outgassing rate in thin wall stainless steel cells

S S Inayoshi, S Tsukahara and A Kinbara 281 Decrease of water vapor desorption by Si film coating on stainless steel

K Akaishi, K Ezaki, Y Kubota and O Motojima 285 Reduction of water outgassing and UHV production in an unbaked vacuum chamber by neon gas discharge

S Ichimura, K Kokubun, M Hirata, S Tsukahara, K Saito and Y Ikeda 291 Measurement of outgassing characteristics from a vacuum chamber fabricated for pressure calibration in UHV/XHV region

R A Nevshupa, J L de Segovia and E A Deulin 295 Outgassing of stainless steel during sliding friction in ultra-high vacuum

P Řepa and D Orálek 299 Outgassing stimulated by deformation

K H Chung, S K Lee, Y H Shin, J Y Lim, S S Hong and S H Be 303 The outgassing from TiN and BN films grown on stainless steel by IBAD

Y Hirohata, M Okegawa, H Yanagihara, T Hino, N Ogiwara, J Yagyu and M Saidoh 309 Gas desorption properties of tungsten coated graphite materials

H Nörenberg, T Miyamoto, N Fukugami, Y Tsukahara, G D W Smith and G A D Briggs 313 Permeation of gases through polymer membranes investigated by mass spectroscopy

Surface Treatment

C Benvenuti, G Canil, P Chiggiato, P Collin, R Cosso, J Guérin, S Ilie, D Latorre and K S Neil 317 Surface cleaning efficiency measurements for UHV applications

S Tada, Y Sakamoto, T Suzuki, H Saito, M Oikawa, A Kidokoro and H Enoki 321 Experiment on removing hydrocarbon by using RF oxygen or hydrogen plasma

S S Inayoshi, Y Sato, K Saito, S Tsukahara, Y Hara, S Amano, K Ishizawa, T Nomura, A Shimada and M Kanazawa 325 Chemical polishing of stainless steel for ultrahigh vacuum wall material

Particulates

J M Jimenez, J L Dorier and N Hilleret 329 Measurements of particulate contamination and migration under vacuum using a large sensitive area particle counter

A A Bochkarev, V I Poliakova and M V Pukhovoy 335 Two mechanisms of formation of a dust in vacuum chambers

Vacuum Systems

A Morris and J M Dyke 339 Safe handling of corrosive chemicals in a vacuum environment: a case study – photoelectron spectroscopy of reactive intermediates

H C Hseuh, R Davis, D Pate, L Smart R Todd and D Weiss 347 RHIC vacuum systems

Y Saito, Y Ogawa, G Horikoshi, N Matuda, R Takahashi and M Fukushima 353 Vacuum system of the 300 m gravitational wave laser interferometer in Japan (TAMA300)

J C Orchard and S C Scales 357 The JET vacuum interspace system

P Beer, M A Djouadi, R Marchal, A Sokolowska, M Lambertin, A Czyzniewski and W Prochi 363 Antiabrasive coatings in a new application – wood rotary peeling process

Volume 53 Numbers 3–4

AUTHORS ARTICLES

Steslicka 367 Preface

W. Arabczyk, D. Moszyński and U. Narkiewicz 369 The comparison of the different adsorption states of non-metals on the iron surface

J.J. Czyżewski and J. Krajniak 375 Desorption Induced by Electron Transition (DIET) of O^+ and HOH^+ ions from H_2O/Ag(0 0 1) adsorption system

W. Lisowski 379 Flow technique for measuring the sticking probabilities of simultaneously adsorbed gases on metal films: application to the simultaneous adsorption of deuterium and nitrogen on thin iron film at 78 K

Ya.B. Losovyj 385 Atomic and electronic structures of Gd submonolayers adsorbed on Mo(1 1 2) surface

Ya.B. Losovyj and N.T. Dubyk 391 Adsorption of Ho on Mo(1 1 2) crystal face

P.M. Møller, P.J. Godowski and J. Onsgaard 397 Adsorption and decomposition of formic acid on potassium-modified Cu(1 1 0)

E. Rówiński and E. Łągiewka 403 Cini's models in studies of carbon and oxygen chemisorption on the TiNi alloys surface

M. Tuleta 407 The influence of plasma processing on the surface composition of float glass

A.S. Yanovsky and S.V. Kolomoets 413 Hydrogen interaction with Si and Ge surface clusters

R. Czajka, S. Mielcarek, B. Mróz, S. Kaszczyszyn and J. Albers 419 Atomic force microscopy studies of $Gd_2(MoO_4)_3$ crystal surface

E. Czerwosz, P. Dłużewski, R. Nowakowski and H. Wronka	423	Topography and structure of C_{60}/C_{70}+Ni film containing carbon nanotubes grown perpendicularly to the substrate
T. Klimczuk, W. Sadowski and J. Szmytkowski	429	The influence of the temperature treatment on the $Nd_{2-x}Ce_xCuO_{4-y}$ crystals surface
A. Lukaszewski and A. Szczepkowicz	433	Computer simulation of FIM images – the convex hull model
M. Nowicki	439	Directional Auger and directional elastic peak electron spectroscopies: experimental and theoretical approach
H. Otop, S. Mróz and Z. Jankowski	445	Silver ultrathin layer growth on the Cu(1 1 1) face at temperatures from 130 to 570 K
W. Soszka, N.-T. Kim-Ngan, D. Sitko, G. Jaglo and A. Kozlowski	449	Ion scattering from the single-crystal magnetite Fe_3O_4 under the Verwey transition
A. Szczepkowicz and A. Ciszewski	455	Faceting of tungsten microcrystal induced by platinum adsorption—FIM study
G. Balcerowska, A. Bukaluk, R. Siuda, J. Seweryn and M. Rozwadowski	459	Grain boundary diffusion of Pd through Ag thin layers evaporated on polycrystalline Pd in high vacuum studied by means of AES, PCA and FA
T. Biernat and A.M. Dąbrowski	465	Diffusion of titanium on tungsten investigated by the current fluctuation method in FEM
R. Bryl and R. Blaszczyszyn	469	Surface diffusion of water on clean and Au-covered tungsten field emitter tips
F. Máca, M. Kotrla and O.S. Trushin	479	Energy barriers for diffusion on stepped Pt(1 1 1) surface
F. Nieto and C. Uebing	485	Surface diffusion on heterogeneous surfaces: Competition between ordering and heterogeneity effects
P. Hądzel and T. Radoń	491	Optical transitions in the titanium $\langle 0\,0\,0\,1 \rangle$ band structure
L. Jurczyszyn and B. Stankiewicz	497	Scanning tunneling spectroscopy of d states from a transition metal surface: theoretical study
S.V. Man'kovsky and V.T. Cherepin	503	Magnetism of V monolayers on Fe(1 0 0) and Cr(1 0 0)
P. Mlynarski, M. Iglesias, M. Pereiro, D. Baldomir and L. Wojtczak	509	Properties and structure of small cobalt clusters. Nonlocal density functional calculations
P. Mlynarski, M. Iglesias, M. Pereiro, D. Baldomir and L. Wojtczak	517	Nonlocal density functional study of mixed copper–cobalt clusters
B. Stankiewicz and L. Jurczyszyn	521	Electronic structure of thin films of zinc-blende GaN(0 0 1): LCAO calculation
R. Taranko and E. Taranko	527	Resonant electron transfer in ion/atom–metal surface interactions within generalized Anderson–Newns model
A.A. Wronkowska, A. Wronkowski and H. Arwin	533	Pd-induced effects in the electronic structure of thin Cu and Au films
B. Adamowicz and H. Hasegawa	539	Computer simulations of the surface photovoltage on Si and GaAs surfaces with U-shaped surface state continuum
V. Gorbenko, A. Gorban and J. Shvets	545	Effects of H-atoms on basic processes in H_2/H_2O/InP system
S. Kochowski and M. Nowak	549	An analysis of small-signal response of the SiO_2–(n) GaAs interface based on a surface disorder model

S. Kuźmiński	555	Surface electronic structure investigations of CdTe and $Cd_{0.98}Fe_{0.02}Te$ via the surface photovoltage spectroscopy method
G. Balcerowska and R. Siuda	561	Inelastic background subtraction from a set of angle-dependent XPS spectra using PCA and polynomial approximation
G. Gergely, A. Barna, A. Sulyok, C. Jardin, B. Gruzza, L. Bideux, C. Robert, J. Toth and D. Varga	567	Crystalline effects in elastic peak electron spectroscopy
A. Król, J. Szuber and S. Kaszczyszyn	571	Application of the unipole mass filter for determination of the partial pressure of gases with near atomic mass number
J. Pavluch, J. Slezák and E. Tomková	577	On the interpretation of some overlayer experiments
B. Susla, W. Sadowski, R. Czajka, M. Kamiński and M. Nowicki	581	Surface analysis of $PrBa_2Cu_3O_{7-x}$ single crystals using scanning tunneling spectroscopy and microscopy
L. Wicikowski, B. Kusz, L. Murawski, K. Szaniawska and B. Susla	587	AFM and XPS study of nitrided TiO_2 and SiO_2–TiO_2 sol–gel derived films
B. Bialek	593	Hydrogen interaction with isolated atoms and ions of transition metal
A.I. Elizarov and A.V. Sukachov	599	New method for visualizing heterogeneous reactions
A. Hammoudeh, M.S. Mousa and J. Loboda-Cackovic	605	Interaction of CO with clean and oxygen covered PdCu(110) single crystal alloy
S. Kruszewski and T. Kobiela	611	AFM and optical investigations of SERS-active silver electrodes
M.S. Mousa, A. Hammoudeh and J. Loboda-Cackovic	617	Chemisorption of nitrogen on PdCu(1 1 0) single-crystal alloy
Z. Stępień	623	Interaction of hydrogen with tantalum surface in a high electric field
P. Biegański, E. Dobierzewska-Mozrzymas, E. Pieciul and J. Wójcik	629	Description of Mn discontinuous films nanostructures
H. Bogdanów and K.F. Wojciechowski	635	Size-dependent work function of ultrathin jellium films
A. Budkowski, J. Rysz, F. Scheffold, J. Klein, A. Bernasik and J. Jedliński	639	Surface segregation in the minority component of the binary polymer mixture
A. Bukaluk	645	AES studies of interdiffusion in thin-film copper–palladium multilayer structures
J. Chrzanowski	651	Thermally stimulated electron emission of YBaCuO sandwich sample
E. Dobierzewska-Mozrzymas, J. Wójcik, P. Biegański and E. Pieciul	655	Application of the effective medium theories to interpret the optical properties of Mn discontinuous films
W. Karaś	661	Hyperfine fields in Fe–Cr thin films
P. Mazur	665	Photoemission study of CaF_2/LiBr Interface
J. Rysz, H. Ermer, A. Budkowski, M. Lekka, A. Bernasik, S. Wróbel, R. Brenn, J. Lekki and J. Jedliński	669	Depth profiling studies of the surface directed phase decomposition in thin polymer films
B. Djafari Rouhani and A. Khelif	675	Localized and resonant acoustic waves associated with a periodic array of supported wires
A. Šiber, B. Gumhalter and J.P. Toennies	681	Study of energy transfer in helium atom scattering from surfaces

Volume 54 Numbers 1–4

Proceedings of the 19th International Seminar on Surface Physics

AUTHORS		ARTICLES
Maria Stęślicka, Robert Kucharczyk and Antoni Ciszewski	1	Preface

ADSORPTION AND DESORPTION

W Arabczyk, D Moszyński and U Narkiewicz	3	The comparison of the different adsorption states of non-metals on the iron surface
J J Czyżewski and J Krajniak	9	Desorption Induced by Electron Transition (DIET) of O^+ and HOH^+ ions from H_2O/Ag(0 0 1) adsorption system
W Lisowski	13	Flow technique for measuring the sticking probabilities of simultaneously adsorbed gases on metal films: application to the simultaneous adsorption of deuterium and nitrogen on thin iron film at 78 K
Ya B Losovyj	19	Atomic and electronic structures of Gd submonolayers adsorbed on Mo(1 1 2) surface
Ya B Losovyj and N T Dubyk	25	Adsorption of Ho on Mo(1 1 2) crystal face
P M Møller, P J Godowski and J Onsgaard	31	Adsorption and decomposition of formic acid on potassium-modified Cu(1 1 0)
E Rówiński and E Łągiewka	37	Cini's models in studies of carbon and oxygen chemisorption on the TiNi alloys surface
M Tuleta	41	The influence of plasma processing on the surface composition of float glass
A S Yanovsky and S V Kolomoets	47	Hydrogen interaction with Si and Ge surface clusters

ATOMIC STRUCTURE AND TOPOGRAPHY

R Czajka, S Mielcarek, B Mróz, S Kaszczyszyn and J Albers	53	Atomic force microscopy studies of $Gd_2(MoO_4)_3$ crystal surface
E Czerwosz, P Dłużewski, R Nowakowski and H Wronka	57	Topography and structure of C_{60}/C_{70} + Ni film containing carbon nanotubes grown perpendicularly to the substrate
T Klimczuk, W Sadowski and J Szmytkowski	63	The influence of the temperature treatment on the $Nd_{2-x}Ce_xCuO_{4-y}$ crystals surface
A Łukaszewski and A Szczepkowicz	67	Computer simulation of FIM images – the convex hull model
M Nowicki	73	Directional Auger and directional elastic peak electron spectroscopies: experimental and theoretical approach
H Otop, S Mróz and Z Jankowski	79	Silver ultrathin layer growth on the Cu(1 1 1) face at temperatures from 130 to 570 K
W Soszka, N-T. H Kim-Ngan, D Sitko, G Jagło and A Kozłowski	83	Ion scattering from the single-crystal magnetite Fe_3O_4 under the Verwey transition
A Szczepkowicz and A Ciszewski	89	Faceting of tungsten microcrystal induced by platinum adsorption—FIM study

DIFFUSION

G Balcerowska, A Bukaluk, R Siuda, J Seweryn and M Rozwadowski	93	Grain boundary diffusion of Pd through Ag thin layers evaporated on polycrystalline Pd in high vacuum studied by means of AES, PCA and FA
T Biernat and A M Dąbrowski	99	Diffusion of titanium on tungsten investigated by the current fluctuation method in FEM
R Bryl and R Błaszczyszyn	103	Surface diffusion of water on clean and Au-covered tungsten field emitter tips
F Máca, M Kotrla and O S Trushin	113	Energy barriers for diffusion on stepped Pt(1 1 1) surface
F Nieto and C Uebing	119	Surface diffusion on heterogeneous surfaces: competition between ordering and heterogeneity effects

ELECTRONIC STRUCTURE

P Hądzel and T Radoń	125	Optical transitions in the titanium ⟨0 0 0 1⟩ band structure
L Jurczyszyn and B Stankiewicz	131	Scanning tunneling spectroscopy of d states from a transition metal surface: theoretical study
S V Man'kovsky and V T Cherepin	137	Magnetism of V monolayers on Fe(1 0 0) and Cr(1 0 0)
P Młynarski, M Iglesias, M Pereiro, D Baldomir and L Wojtczak	143	Properties and structure of small cobalt clusters. Nonlocal density functional calculations
P Młynarski, M Iglesias, M Pereiro, D Baldomir and L Wojtczak	151	Nonlocal density functional study of mixed copper–cobalt clusters
B Stankiewicz and L Jurczyszyn	155	Electronic structure of thin films of zinc-blende GaN(0 0 1): LCAO calculation
R Taranko and E Taranko	161	Resonant electron transfer in ion/atom–metal surface interactions within generalized Anderson–Newns model
A A Wronkowska, A Wronkowski and H Arwin	167	Pd-induced effects in the electronic structure of thin Cu and Au films

SEMICONDUCTORS

B Adamowicz and H Hasegawa	173	Computer simulations of the surface photovoltage on Si and GaAs surfaces with U-shaped surface state continuum
V Gorbenko, A Gorban and J Shvets	179	Effects of H-atoms on basic processes in H_2/H_2O/InP system
S Kochowski and M Nowak	183	An analysis of small-signal response of the SiO_2–(n) GaAs interface based on a surface disorder model
S Kuźmiński	189	Surface electronic structure investigations of CdTe and $Cd_{0.98}Fe_{0.02}Te$ via the surface photovoltage spectroscopy method

SPECTROSCOPIC METHODS

G Balcerowska and R Siuda	195	Inelastic background subtraction from a set of angle-dependent XPS spectra using PCA and polynomial approximation
G Gergely, A Barna, A Sulyok, C Jardin, B Gruzza, L Bideux, C Robert, J Toth and D Varga	201	Crystalline effects in elastic peak electron spectroscopy
A Król, J Szuber and S Kaszczyszyn	205	Application of the unipole mass filter for determination of the partial pressure of gases with near atomic mass number
J Pavluch, J Slezák and E Tomková	211	On the interpretation of some overlayer experiments

B Susła, W Sadowski, R Czajka, M Kamiński and M Nowicki 215 Surface analysis of $PrBa_2Cu_3O_{7-x}$ single crystals using scanning tunneling spectroscopy and microscopy

L Wicikowski, B Kusz, L Murawski, K Szaniawska and B Susła 221 AFM and XPS study of nitrided TiO_2 and SiO_2–TiO_2 sol–gel derived films

SURFACE REACTIONS

B Białek 227 Hydrogen interaction with isolated atoms and ions of transition metal

A I Elizarov and A V Sukachov 233 New method for visualizing heterogeneous reactions

A Hammoudeh, M S Mousa and J Loboda-Cackovic 239 Interaction of CO with clean and oxygen covered PdCu(1 1 0) single crystal alloy

S Kruszewski and T Kobiela 245 AFM and optical investigations of SERS-active silver electrodes

M S Mousa, A Hammoudeh and J Loboda-Cackovic 251 Chemisorption of nitrogen on PdCu(1 1 0) single-crystal alloy

Z M Stępień 257 Interaction of hydrogen with tantalum surface in a high electric field

THIN FILMS AND INTERFACES

P Biegański, E Dobierzewska-Mozrzymas, E Pieciul and J Wójcik 263 Description of Mn discontinuous films nanostructures

H Bogdanów and K F Wojciechowski 269 Size-dependent work function of ultrathin jellium films

A Budkowski, J Rysz, F Scheffold, J Klein, A Bernasik and J Jedliński 273 Surface segregation in the minority component of the binary polymer mixture

A Bukaluk 279 AES studies of interdiffusion in thin-film copper–palladium multilayer structures

J Chrzanowski 285 Thermally stimulated electron emission of YBaCuO sandwich sample

E Dobierzewska-Mozrzymas, J Wójcik, P Biegański and E Pieciul 289 Application of the effective medium theories to interpret the optical properties of Mn discontinuous films

W Karaś 295 Hyperfine fields in Fe–Cr thin films

P Mazur 299 Photoemission study of CaF_2/LiBr interface

J Rysz, H Ermer, A Budkowski, M Lekka, A Bernasik, S Wróbel, R Brenn, J Lekki and J Jedliński 303 Depth profiling studies of the surface directed phase decomposition in thin polymer films

VIBRATIONAL PROPERTIES

B Djafari Rouhani and A Khelif 309 Localized and resonant acoustic waves associated with a periodic array of supported wires

A Šiber, B Gumhalter and J P Toennies 315 Study of energy transfer in helium atom scattering from surfaces

Volume 55 Number 1

AUTHORS ARTICLES

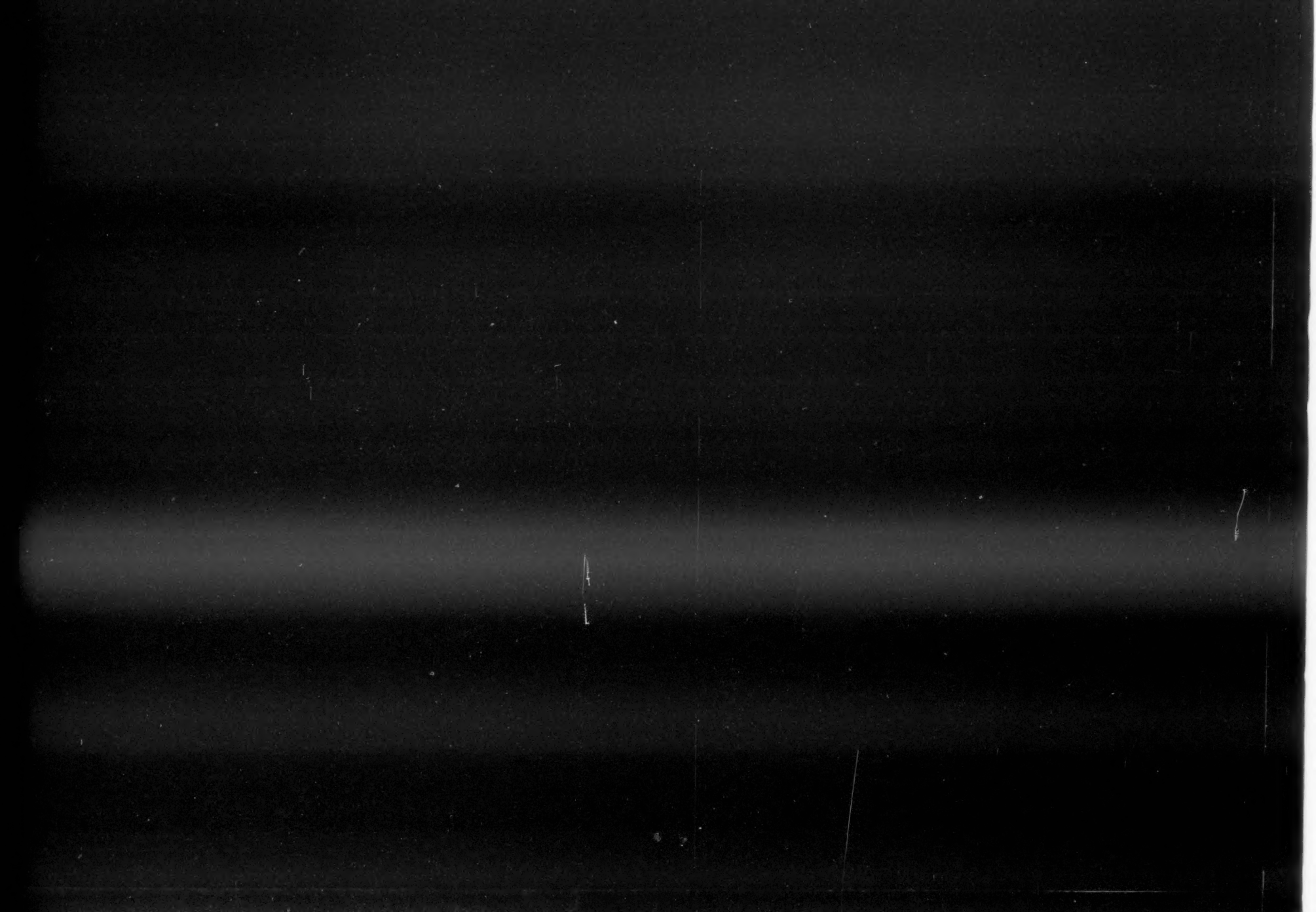
H Navarrete, R Bullich, J L de Segovia, and J Antó i Roca 1 Calibration of absolute pressure gauges in the range from 130 kPa to 0.1 Pa

L I Antonova and V P Denissov	7	High-brightness electron source isolated from the ambient atmosphere
A Grzeszczak, S Kaszczyszyn and S Klein	13	Spectral density of elastically backscattered electrons from polycrystalline titanium
S M Firoz Hasan, L Quadir, Kh S Begum, M A Subhan and Kh M Mannan	17	Dependence of the type of electrical conduction on the composition of $CuInSe_2$-thin films
A Fissore, M A R Alves, E da Silva Braga and L Cescato	23	Mask of amorphous hydrogenated carbon films applied to chemical polishing and chemical dicing of silicon wafers
R Giannantonio, M Bovisio and A Conte	27	Combination of a getter pump with turbomolecular pumps in UHV applications
S Da-Ming, S Zhao-Qi, L Ai-Xia and X Zhi-Yuan	39	Oxidation behaviour of MgF_2 in Ag–MgF_2 cermet
J Smolik, K Zdunek and B Larisch	45	Investigation of adhesion between component layers of a multi-layer coating $TiC/Ti(C_x, N_{1-x})/TiN$ by the scratch-test method
A Galdikas	51	Surface topography development and ion mixing in the study of depth profiling of multilayered structures
E Paparazzo and L Moretto	59	X-ray photoelectron spectroscopy and scanning Auger microscopy studies of bronzes from the collections of the Vatican Museums
R Jeyakumar, S T Lakshmikumar and A C Rastogi	71	Parametric investigation for the optimization of ZnSe film formation by low-pressure Se vapour selenization process
H Kinoshita	77	Sub-half micron etching of resist below room temperature using O_2 supermagnetron plasma
V M Fuenzalida, M E Pilleux and I Eisele	81	Adsorbed water on hydrothermal $BaTiO_3$ films: work function measurements
R Bryl	85	Dissociation of water deposited on W field emitter tip
BOOK REVIEWS	91	
VACUUM DIARY	I	

Volume 55 Number 2

AUTHORS		ARTICLES
A Verma, K J S Sawhney, S Chatterjee and R V Nandedkar	95	A UHV compatible precision mirror movement mechanism for use in synchrotron radiation beamlines
K A Chuntonov, V G Postovalov and A G Kesarev	101	Evaporation of volatile component from intermetallic granule with non-volatile component shell
L A Donohue, D B Lewis, W-D Münz, M M Stack, S B Lyon, H-W Wang and D Rafaja	109	The influence of low concentrations of chromium and yttrium on the oxidation behaviour, residual stress and corrosion performance of TiAlN hard coatings on steel substrates
V D Borman, S V Gubanov, Yu Yu Lebedinski, Yu M Pustovoit, V L Stoliarov, V I Troyan, R M Caloi and A Conte	115	Nonequilibrium processes on TiV surface induced by activation and absorption of gases

S S Hullavarad, S V Bhoraskar, S R Sainkar, S Badrinarayanan, A B Mandale and V Ganesan	121	Deep levels in GaN grown by nitridation of GaAs (1 1 0) surface in a electron cyclotron–resonance ammonia plasma
H-F Huang	127	Investigtaion on composition and structure of ZnS : Mn evaporation films with sulfur supply
D C York, A Chambers, A D Chew and A P Troup	133	Measurement of thermal transpiration across an array of parallel capillaries using a differential capacitance manometer
J Jiruše and T Šikola	141	Application of simple kinematic predictions for the structural search in LEED
J Smolik and K Zdunek	147	Effect of interlayer composition on the tribological properties of TiC/Ti(C_x, N_{1-x})/TiN anti-abrasive multi-layer coatings
S Collard, H Kupfer, W Hoyer and G. Hecht	153	Growth of nitrogen stabilised cubic ZrO_2 phase by reactive magnetron sputtering using two reactive gases
S A Aly, S A Mahmoud, N Z El-Sayed and M A Kaid	159	Study on some optical properties of thermally evaporated V_2O_5 films
P Špatenka, J Vlček and J Blažek	165	Langmuir probe measurements of plasma parameters in a planar magnetron with additional plasma confinement
M Benda and J Musil	171	Plasma nitriding enhanced by hollow cathode discharge – a new method for formation of superhard nanocomposite coatings on steel surfaces
VACUUM DIARY	I	

Volume 55 Numbers 3–4

AUTHORS		EDITORIAL
L Hultman and J. Colligon	177	New series on materials science aspects of PVD hard coatings
		ARTICLES
P C Yashar and W D Sproul	179	Nanometer scale multilayered hard coatings
P W Leech	191	Reactive ion etching of quartz and silica-based glasses in CF_4/CHF_3 plasmas
H W Zhang, Z Y Zhong, Y L Liu and H C Wang	197	Improvement of thin film transformer characteristics by use of a new fabrication process
H S Metwally, A Ashery, F S Terra and A A El-Shazly	201	Dark *C–V* and *I–V* characteristics of silicon multi-junctions prepared by liquid-phase epitaxy
Z Q Ma, B X Liu, H Naramoto, Y Aoki, S Yamamoto, H Takeshita and P C Goppelt-Langer	207	Non-destructive characterization of ion-implanted diamond
H Kinoshita, M Honda, T Tatsuta and F Sakiya	219	Analysis of the negative ion characteristics of O_2 supermagnetron plasma for submicron etching use
J Felba	223	Emittance of high-power-density electron beam
G Carter	235	Island-density and size dynamics in ion-assisted atomic deposition
N J Kadhim and D Mukherjee	249	Growth defects associated with MBE deposited GaAs layers
W Steckelmacher	255	BOOK REVIEW
	I	VACUUM DIARY